

		Subclass
	Class	
		ISSUE CLASSIFICATION

PATENT NUMBER

U.S. UTILITY Patent Application

O.I.P.E.

PATENT DATE

SCANNED 1/30/03

APPLICATION NO. 09/614286	CONT/PRIOR F	CLASS 438	SUBCLASS 199	ART UNIT 2812	EXAMINER Kielin
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APPLICANTS
Hiroshi Tanabe

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 Method for forming semiconductor films at desired positions on a substrate

PTO-2040
12-93

ISSUING CLASSIFICATION					
ORIGINAL		CROSS REFERENCE(S)			
CLASS	SUBCLASS	CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)		
INTERNATIONAL CLASSIFICATION					
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TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets	Drawg.	Figs. Drawg.	Print-Fig.	Total Claims
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	(Assistant Examiner) (Date)			NOTICE OF ALLOWANCE MAILED	
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent No. _____	(Primary Examiner) (Date)			ISSUE FEE	
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